Shanghai head office

Shanghai Fortrend Technology Co.,Ltd Tel: 021-34786180 Web : cn.fortrend.com Sale E-mail : sales@fortrend.com.cn Address: No. 555 Wanfang Road, Minhang District, Shanghai P.R. China





wechat

Zhejiang subsidiary

Zhejiang Fortrend Technology Co.,Ltd Tel : 17521176476 Sale E-mail : sales@fortrend.com.cn Address: No. 139, Chuangxin Road, Xindai Town, Pinghu City, Zhejiang Province, P.R. China

Wuxi subsidiary

Wuxi Fortrend Intelligent Technology Co.,Ltd Tel :13480952530 E-mail):liuhp775@fortrend.com.cn Address: 100 Meiyu Road, Meicun Street, Xinwu District, Wuxi City

Wuxi Fortrend Precision Equipment Co.,Ltd Tel : 13530760646 Sale e-mail : zhengqbfcd307@fortrend.com.cn Address: 100 Meiyu Road, Meicun Street, Xinwu District, Wuxi City

USA subsidiary

Fortrend Engineering Corporation

Tel: (1) 408-734-9311 Sale e-mail : sales@fortrend.com Address: 2220 O' Toole Avenue, San Jose USA, CA95131

Distributors

UK

Sistem Technology Address: Grafton Suite, Caswell Science & Technology Park, Towcester, Northants, NN12 8EQ, UK Tel: (44) 1327 317621

South Korea SD Solution Address: #509,Biz-tower,63-12,Dongtancheomdansaneop 1-ro,Hwaseong-si,Gyeonggi-do,Republic of korea Tel: (81) 42-468-4164

The product pictures shown in this volume are rendered or taken. The technical parameters and pictures may be different from the actual products due to improvement and upgrade, etc., for reference only. Please confirm with your account manager for details

SEMICONDUCTOR WAFER AUTOMATIC TRANSMISSION SYSTEM TOTAL SOLUTION









CATALOGUE



WAFER STANDARD MECHANICAL INTERFACE

WAFER SORTER

EFEM(EQUIPMENT FRONT END MODOLE)

EFEM & STORAGE SYSTEM

FULL AUTOMATIC RETICLE HANDLING SYSTEM

AUTOMATED STORAGE SYSTEM(STOCKER)

P-RACK AUTOMATED GUIDED VEHICLE

FRONT LOAD AUTOMATED MOBILE ROBOT(AMR) -----

WAFER TRANSFER ROBOT

300MM LOAD PORT

200MM LOAD PORT

SEMICONDUCTOR VACUUM TRANSFER SYSTEM

 03
 05
 07
 09
 11
 13
 15
17
 19
 21
 23
 25

ABOUT FORTREND

Shanghai Fortrend Technology Co., Ltd. is a high-tech enterprise, a small giant enterprise of science and technology, and a SRDI company. It settled in Minhang District, Shanghai, in March 2017 and has four subsidiaries, namely: Zhejiang Fortrend Technology Co., Ltd., Wuxi Fortrend Intelligent Technology Co., Ltd., Wuxi Fortrend Precision Equipment Co., Ltd., and Fortrend Engineering Corporation.

Since its establishment, the company has been deeply engaged in R&D, production, and sales of semiconductor wafer automatic transfer, and is committed to building an intergrated total solution provider with semiconductor wafer transfer and mask transfer automation system at its core. With over 45 years of technical accumulation and experience inheritance in the semiconductor industry, the company has achieved independent research and development of domestic products in technologies such as front-end wafer transfer and storage systems (SORTER/EFEM), Standard Mechanical Interfaces (SMIF), vacuum wafer transfer system (VTM), wafer transfer robot (Robot), wafer loading system (LoadPort), automatic wafer alignment device (Aligner), ultra-clean mask/EUV automation solutions, automatic mobile robot (AMR), and automatic wafer storage system. It provides the semiconductor field with system customization and integration solutions that are competitive in the industry.





Wuxi Fortrend Intelligent Technology Co.,Ltd Wuxi Fortrend Precision Equipment Co., Ltd

Zhejiang Fortrend Technology Co.,Ltd

Shanghai Fortrend Technology Co.,Ltd

Fortrend Engineering Corporation







FORTREND MILESTONE



Specification parameter

Models	PLUS500S/PLUS500R/PLUS500Sx/PLUS500Cx/PLUS500F/PLUS500Ux/PLUS500Sd
Applicable carrier types	200mm SMIF Pod (SEMI)
Carrier Load Height	900 mm (tailor to fit specific needs)
Cleanliness	Class 1 (ISO-Class 3)
Comm Mode	Parallel I/0 (SEMI E23-96) 8 in / outputs or EIA-RS232(SECS I/II)
Cycle Time	< 90 sec (with tilt and lateral movements)
Lot ID Reader	Smart tag / RFID tag

Axis - Gripper positioning accuracy	\pm 0.1 mm
Axis - Arm Elevator positioning accuracy	\pm 0.1 mm
Axis - Arm Extent positioning accuracy	\pm 0.1 mm
Axis - Tilt positioning accuracy	\pm 0.1 mm
Axis - Wrist positioning accuracy	\pm 0.1 mm
MTBF	> 2000 Hours
Up time	≥ 99.5 %





)4



Specification parameter

Rated voltage	Single Phase AC 220V 50/60 Hz
Rated power	3.52kW (Decide by config)
Body material	Painted SPCC (RAL 9003)
Comm interface	RJ45
Comm protocol	HSMS&SECS II
Software	Fortrend custom configuration software
Cleanliness	Class 1 (ISO-Class 3)
End-effector	Vacuum blade / edge grip / Bernoulli / custom
Load Port	2 ~ 4 Ports (optional compatible open cassette)
Applicable carrier types	cassette、SMIF Pod、FOUP/FOSB (SEMI)
Gas pressure supply	VAC : - 70 ~ - 90 kPa, >10LPM (Ø6 air tube) CDA : 0.4 ~ 0.6 MPa, >10LPM (Ø6 air tube)

Applicable wafer materials	Si、SiC etc. (Decide by co
Applicable specif. types	Dia. 100 ~ 300 mm (4 inc
Robot repeatability	\pm 0.1 mm
Aligner initial offset	Max 6 mm
Aligner centering	\pm 0.1 mm (Decide by cc
Aligner angular offse	\pm 0.1 ° (Decide by conf
Aligner notch finding time	< 5 sec / pcs
MTBR	< 2 Hours
MTBF	> 4000 Hours
МТВМ	> 6 Months
Wafer breakage rate	<1 Per 100,000 Wafer
Up time	≥ 98 %

С



onfig)

h ~ 12 inch)









It can be connected to a variety of different types of process equipment. and can be customized for process requirements.

C

C

A variety of handling methods and LP combinations, a variety of custom options, can meet the needs of various working conditions

Specification parameter

Rated voltage	Single Phase AC 220V 50/60 Hz
Rated power	3.52kW (Decide by config)
Body material	Painted SPCC (RAL 9003)
Comm interface	RJ45
Comm protocol	ASCI/HEX/HSMS&SECS II
Software	Fortrend custom configuration software
Cleanliness	Class 1 (ISO-Class 3)
End-effector	Vacuum blade / edge grip / Bernoulli / custom
Load Port	2 ~ 4 Ports (optional compatible open cassette)
Applicable carrier types	cassette、SMIF Pod、FOUP/FOSB (SEMI)
Gas pressure supply	VAC : - 70 ~ - 90 kPa, >10LPM (Ø6 air tube) CDA : 0.4 ~ 0.6 MPa, >10LPM (Ø6 air tube)

Applicable wafer materials	Si、SiC etc. (Decide by c
Applicable specif. types	Dia. 100 ~ 300 mm (4 in
Robot repeatability	± 0.1 mm
Aligner initial offset	Max 6 mm
Aligner centering	\pm 0.1 mm (Decide by c
Aligner angular offse	\pm 0.1 ° (Decide by con
Aligner notch finding time	< 5 sec / pcs
MTBR	< 2 Hours
MTBF	> 4000 Hours
MTBM	>6 Months
Wafer breakage rate	< 1 Per 100,000 Wafer
Up time	≥ 98 %

C



config)

nch ~ 12 inch)

WET WAFER TRANSFER&STORAGE SYSTEM



The integration of EFEM and storage stations, combined with the control system developed by Fortrend, can solve the problems of wafer storage and throughput difficulties in complex processes such as Wet bench cleaner, furnace, and implanter.

Built-in multi-mapping function can detect stacked and inclined chips in multiple sections to eliminate the chip collision problem in wafer transfer.

Specification parameter

Equipment dimension	L 2600* W 2100* H 3080 mm
Equipment weight	4500kg (Decide by config)
Rated voltage	Single Phase AC 220V 50 Hz
Rated power	9.9 kW
Body material	Painted SPCC (RAL 9003)
Comm interface	RJ 45
Comm protocol	HEX
Gas pressure supply	VAC : - 80 kPa , >10LPM(Ø8 air tube) CDA : 0.5 ~ 0.7 MPa, >10LPM(Ø16 air tube)
Wafer contact material	PEEK / PTFE Different modoules have different contact materials

Applicable carrier types	300mm FOUP(SEMI)
Applicable wafer materials	Si
Applicable specif types	Dia. 300 mm / Thick. 7
MTTR	< 4H
MTBF	> 1500H
MTBI	>6 Months
Wafer breakage rate	< 1 Per 100,000 Wafer
Up time	≥ 98 %
Softwear	Fortrend Standard con
Aligner notch finding time	Class 1 @ 0.1µm *Only the wafer transfer area

C

C

С



 $775\,\mu\text{m}\pm25\,\mu\text{m}$

nfiguration software

shares the same cleanliness level as cleanroom grade within the Fab.



FULL AUTOMATIC RETICLE HANDLING SYSTEM



Specification parameter

Material	Mask, Reticle, EUV
Carrier	RSP150, RSP200, Dual EUV Pod, Various Shipping Boxes
Read ID Position	Mask and Pellicle
Cleanness Level	Better than ISO Class1
3rd Party particle inspection Station	Measure particles ≥1µm (PDS)

	0° to 360°turn flip and
	N2 or XCDA Blow off G
Optional Bright Light Inspection Station	Mask 1D & 2D Bar Code
	Pellicle ID Reader and
	Mask Chamfer Identific
Mask Thickness Measurement	Repeatability $\leq 0.2 \mu m$







Specification parameter

Equipment dimension	L 5800* W 1600* H 4620 mm(Decide by config)
Applicable carrier types	SMIF Pod、Reticle Box、FOUP/FOSB
Load Port	2 Ports (Optional P-rack Port)
Carrier Load Height	$900 \pm 10 \text{ mm}$
Comm protocol	HSMS or SECS 1 / SECS II
Rated voltage	Single Phase AC 220V 50 Hz
Cleanliness	Class 100 (Optional FFU)
Quakeproof Level	0.3G (M-S>7.0)
Storage Capacity	146+6 carriers (Decide by config)

Max. carrier arm Load	20 kg
Single Continuous Pod In/Out	< 6 sec
Max. moving speed of the carrier arm	2m / s (non-line mo
Max. rotating speed of carrier arm	90°/sec
Carrier arm repeat positioning accuracy	± 0.2mm
MTTR	< 4 Hours
MTBF	> 2000 Hours
MTBI	>6 Months
Up time	≥ 98 %





P-RACK AUTOMATED GUIDED VEHICLE



SLAM laser navigation design and custom map navigation system, to achieve trackless free navigation, easy to cope with a variety of C complex road conditions, more convenient, more flexible.

The self-developed FTC and MCS dispatching and traffic control systems have better algorithms, which can quickly complete the AGV C transportation planning of the whole plant.

Specification parameter

Equipment dimension	L 1000* W 700* H 1180 mm
Equipment weight	300 Kg (Decide by config)
Battery Type	Ternary lithium battery
Battery Capacity	48V, 52Ah
Battery runtime	>8h
Charging Time	0-80%, 2h;0-100%, 3h
Battery Life	Full discharge>500 times; Battery attenuation ratio of 85%, charging and discharging frequency>1500 times
Charging Mode	Manual/Automatic/Quick change
Single shipment	4 pcs (300mm FOUP) (Decide by config)
Applicable carrier types	SMIF Pod、Reticle Box、FOUP/FOSB

Control method	Computer wireless co
Navigation method	SLAM by laser navigat
Comm method	2.4G / 5G WIFI(AMR to
Max. moveing speed	1m/s
Min. Miss Distance	2m
Min. Passage Width	lm
Positioning Accuracy	±10mm,±1°
Up time	≥ 98 %
MTTR	< 4 Hours
MTBF	> 2000 Hours



ontrol & touch screen control

on

AMR server) & HSMS / SECS II (AMR sever to MCS/MES)



FRONT LOAD AUTOMATED MOBILE ROBOT(AMR)

SLAM laser navigation design and custom map navigation system, to achieve trackless free navigation, easy to cope with a variety of complex road conditions, more convenient, more flexible.

The self-developed FTC and MCS dispatching and traffic control systems have better algorithms, which can quickly complete the AGV transportation planning of the whole plant.

Specification parameter

Equipment dimension	1050* W 700* H 1611 mm
Equipment weight	300 Kg (Decide by config)
Battery Type	Ternary lithium battery
Battery Capacity	48V, 52Ah
Battery runtime	> 8 h
Charging Time	0-80%,2h;0-100%,3h
Battery Life	Full discharge>500 times; Battery attenuation ratio of 85%, charging and discharging frequency>1500 times
Charging Mode	Manual/Automatic/Quick change
Single shipment	2+1 pcs (300mm FOUP) (Decide by config)
Applicable carrier types	SMIF Pod、Reticle Box、FOUP/FOSB
Max. Payload	15kg

Drive Type	Dual wheel differentia
Control method	Computer wireless co
Navigation method	SLAM by laser navigat
Comm method	2.4G / 5G WIFI(AMR to
Max. moveing speed	1m / s
Min. Miss Distance	0.1 m
Min. Passage Width	0.9 m
Positioning Accuracy	±10mm, ±1°
Up time	≥ 98 %
MTTR	< 4 Hours
MTBF	> 2000 Hours

C



al drive

ntrol & touch screen control

ion

AMR server) & HSMS / SECS II (AMR sever to MCS/MES)

WAFER TRANSFER ROBOT



Specification parameter

Equipment dimension	L 340* W 340* H 931.2 mm (Decide by config)
Control box size	L 421.5* W 263.5* H 261.5 mm (Without handle)
Device weight	45 ~ 60 Kg (Decide by config)
Rated voltage	Single phase AC 220 V
Rated power	1.1 kW
Body material	Aluminum
End effectors(EEF) Specif	Ceramics / Aluminum / CFRP
Arm qty	Single Arm / Double Arm
Single shipment	VAC - 70 ~ - 90 kPa / CDA 0. 1~ 0.3 MPa
Wafer holding Method	VaCUUM/ eDGE-GRIPPER / bERNOULLI / CLAMP TYPE FORK
Cleanliness	MaxClass 1 @0.1µm

Axis-Zmax speed:	500 mm/S
Axis-Theta max speed	340°/s
Axis-R1& R2 max speed	750 mm/s (non-line motion)
Axis -θ Repeatable positioning accuracy	±0.05°
Repeatable positioningaccuracy	±0.1mm
Axis-Theta max Range of motion	340°
R1&R2 Max stretch	520~685.5mm(200mmWafer)/600~729.4mm(300 mr
Axis-Z max Range of motion	Single Axis-Z:300/400/450/500mm Dual Axis-Z:600 n
Single shipment	2+1 piece (300mm Foup) (Decide by config)
Applicable carrier types	SMIF Pod, Reticle Box, FOUP/FOSB
Arm load	3kg



A variety of end-effector specifications and customizable linear modules to meet a variety of working conditions.

n Wafer)
ım



规格参数 Specification parameter

Equipment dimension	L 586* W 472* H 1349 mm
Equipment weight	66 \pm 0.5kg (Decide by config)
Rated voltage	DC 24 V
Rated power	120 W
Body material	Aluminum, Painted SPCC (RAL9003)
Applicable carrier types	200/300 mm FOUP (SEMI)
Acoustic Noise	\leq 60 dB
Comm interface	Serial RS-232C, Parallel I/O
Comm protocol	HEX

Cleanliness	Class 1 @ 0.1µm
Carrier Load Height	900mm ±10mm
Gas pressure supply	VAC : - 80 kPa (Ø6 a
	CDA: 0.5~0.6 MPa(
	N2(Matching): 0.1 ~
Matching options	N2 purge function (M
	AMHS system comm
	200mm cassette ada
	Mechanical control,



ir tube)

(Ø6 air tube)

0.2 MPa(Ø8 air tube)

MFC control)

unication port

aptor

Electrical control Info Pad





Standard Load Port Universal device, fully compliant with SEMI standards, with high versatility, high compatibility.

Built-in original Mapping system, can be stacked, inclined chip detection, eliminate the chip collision problem in integrated wafer transfer, and can load 120/200 wafers.

• A variety of customized components can be selected to flexibly respond to different working conditions, such as whether is connectecl with OHT.

Specification parameter

Equipment dimension	L 421mm* W 364mm* H815 mm
Equipment weight	40kg (Decide by config)
Rated voltage	DC 24 V
Rated voltage	60 W
Body material	Aluminum、Stainless steel (SUS 304) T
Applicable carrier types	150/ 200mm POD(SEMI)
Acoustic Noise	\leq 60 dB
Comm interface	Serial EIA-RS232C,Paralle I/O
Comm protocol	HEX, SECS

Cleanliness	Class 1 @ 0.1µm
Wafer box interface	SEMI E19.4
Load loop	VAC : - 80 kPa (Ø6 air
Removal loop	CDA: 0.5 ~ 0.6 MPa(Ø
Matching options	150/200mm Open box
	E84 Electric control m
	Communication proto
	ID read/write device w



tube) 6 air tube) x to detect sensor configuration nodule selection pcol module selection HEX/SECS vith RFID module or IR Link



6

Optional features include AWC functionality, Buffer functionality, wafer storage modules.